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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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Applicant: Masayuki SHINOHARA, et al. Art Unit: 2823

Filed July 28, 2003 Examiner: Julio J. Maldonado

Docket No: SUG-168-USAP Customer No: 28892

For: Method of Fabricating a Light Emitting Device, and Light

Emitting Device

RESPONSE TO RESTRICTION REQUIREMENT

US Patent & Trademark Office Customer Service Window, Mail Stop: RESTRICTION Randolph Building 401 Dulany Street Alexandria, VA 22314

Sir:

In response to the Office Action mailed March 31, 2005, Applicant hereby responds to the Restriction Requirement by electing the first species (directed to a light emitting device having a light emitting layer formed by a metal organic vapor phase epitaxy process and a current spreading layer formed by hydride vapor phase epitaxy). Applicant hereby identifies claims 25 - 27, 30, 32, 34, 36, 38 as being readable thereon.

It is respectfully submitted that the above is fully responsive to the Restriction Requirement. Further, it is respectfully submitted that this application is now in condition for examination on the merits, and early action and allowance thereof is accordingly requested.

Respectfully submitted

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Date: April 22, 2005

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